



M&NEMS : A GENERIC PLATFORM FOR MEMS MANUFACTURING

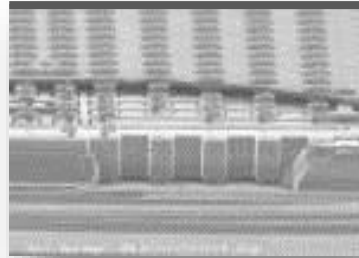
Introduction to LETI's MEMS activities





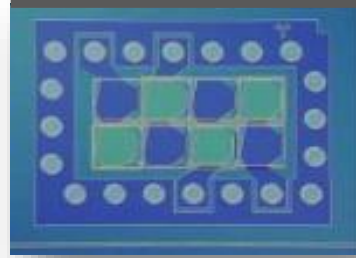
LCMA Lab.

Actuators Components



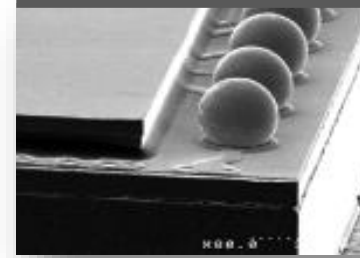
LCMC Lab.

Sensors Components



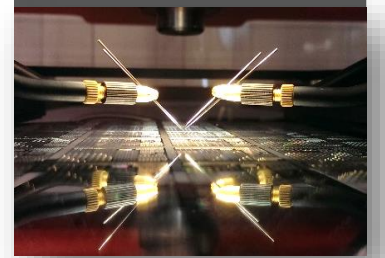
LCRF Lab.

RF Components



LP3D Lab.

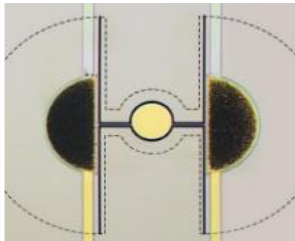
Packaging & 3D



LCFC Lab.

Charact. & Reliability

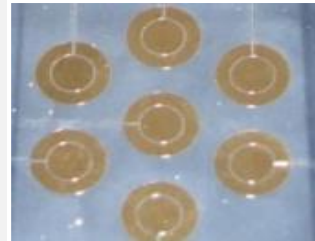
Components



Optical Scanner



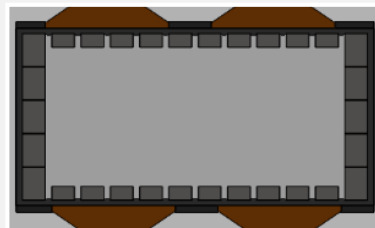
Variable focus lens



Loudspeaker

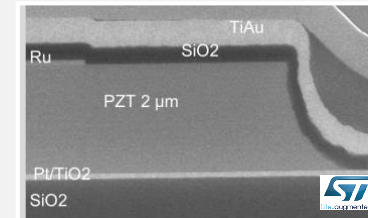


Micro-valve / Micro-pump



Haptics

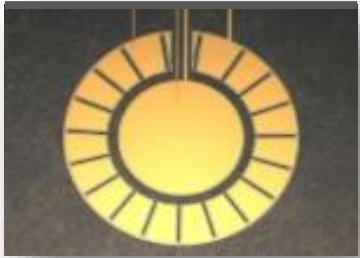
Technologies background



PZT

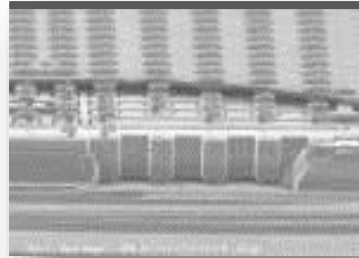


AIN



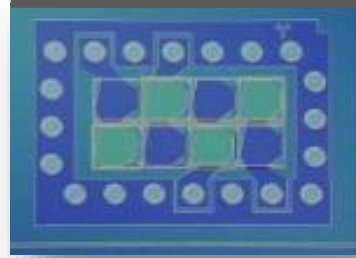
LCMA Lab.

Actuators Components



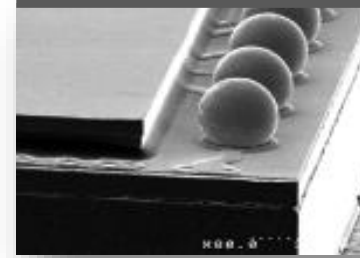
LCMC Lab.

Sensors Components



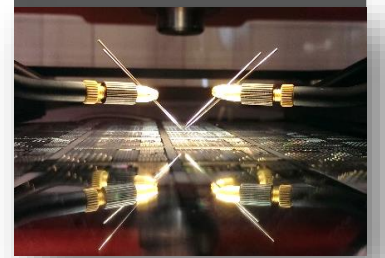
LCRF Lab.

RF Components



LP3D Lab.

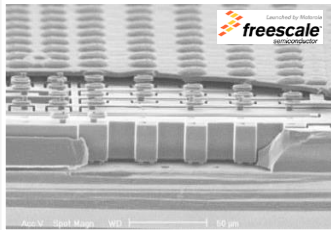
Packaging & 3D



LCFC Lab.

Charact. & Reliability

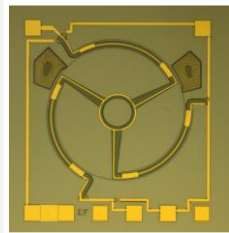
Components



Inertial sensor



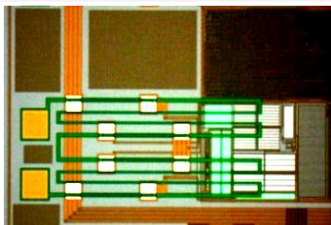
Pressure sensor



Acoustic sensor



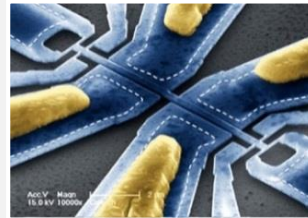
Ultrasonic sensor (MUT)



Magnetic sensor (TMR)



Gas sensor



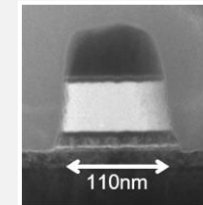
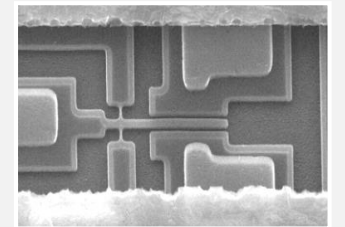
Bio sensor



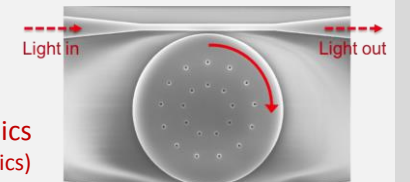
Force sensor

Technologies background

NEMS



Spintronics

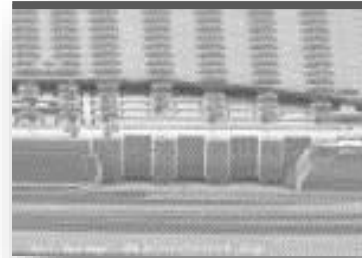


Optomechanics (NEMS + Photonics)



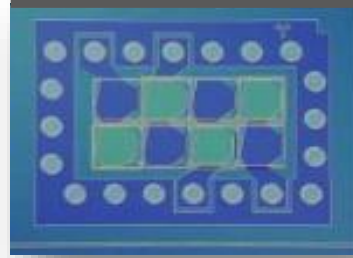
LCMA Lab.

Actuators Components



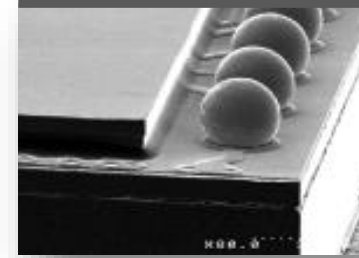
LCMC Lab.

Sensors Components



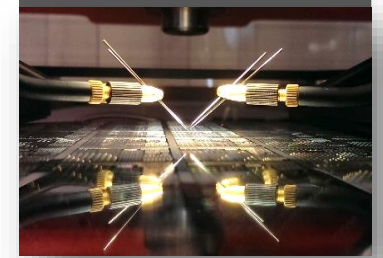
LCRF Lab.

RF Components



LP3D Lab.

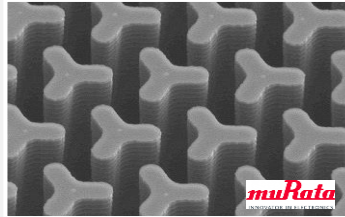
Packaging & 3D



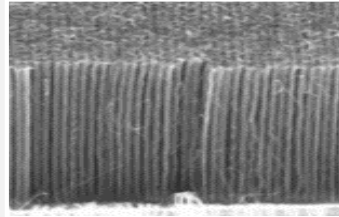
LCFC Lab.

Charact. & Reliability

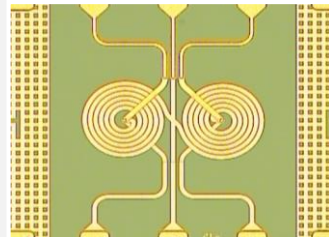
Passive



3D High density capacitor

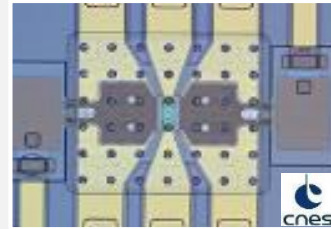


Magnetic inductor

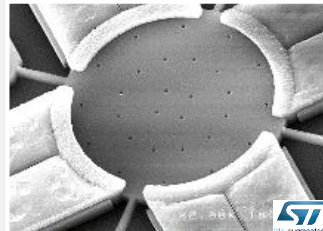
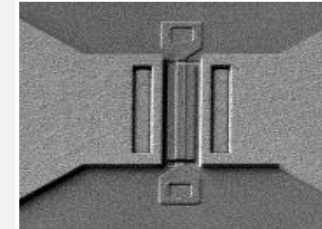


Electro-Magnetic Transformer

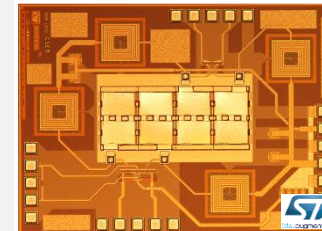
RF-MEMS



RF micro-switch



RF resonator

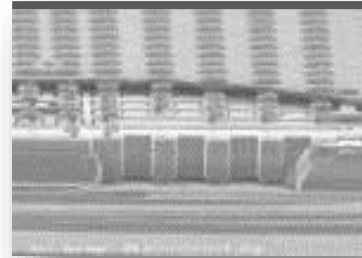


Acoustic Filter



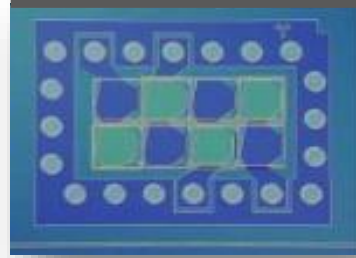
LCMA Lab.

Actuators Components



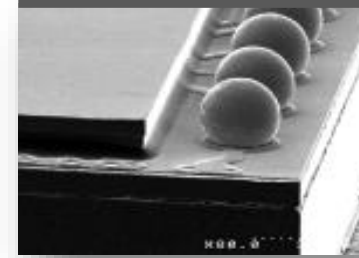
LCMC Lab.

Sensors Components



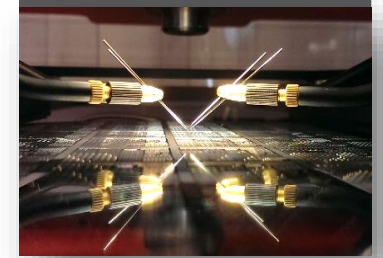
LCRF Lab.

RF Components



LP3D Lab.

Packaging & 3D

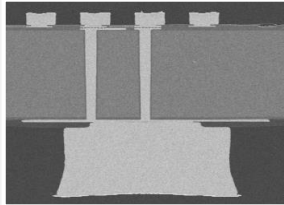


LCFC Lab.

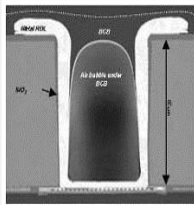
Charact. & Reliability

3D Technology

TSV



TSV-Mid (Cu-filled)

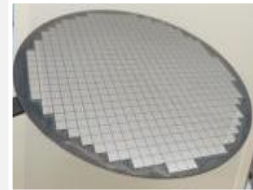


TSV last (Cu-liner)

Wafer process

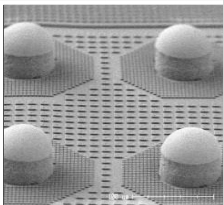


Wafer thinning

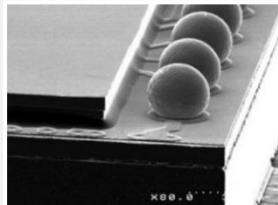


Overmolding

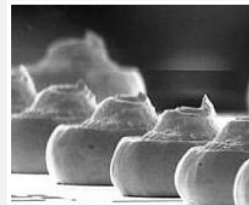
Connecting



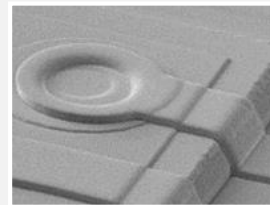
Cu pillars (pitch 40µm)



Bumping - Balling

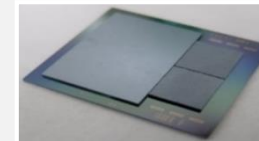


Au stud bumps

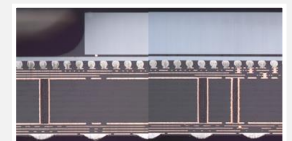


RDL + conformal routing

Si interposers

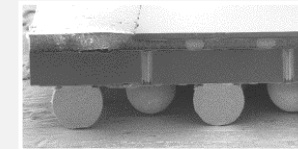


Large interposer



HD interposer

Rebuilt wafer

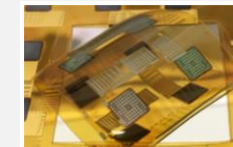


Rebuilt wafer

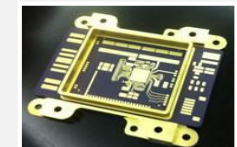


3D power module

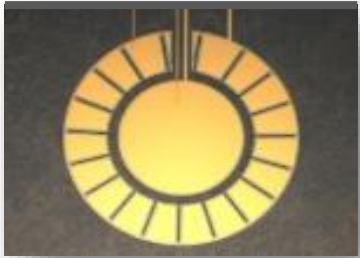
Packaging



Integration in Flex

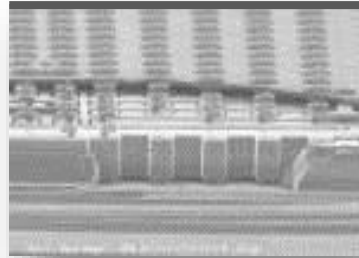


High temp. SiP



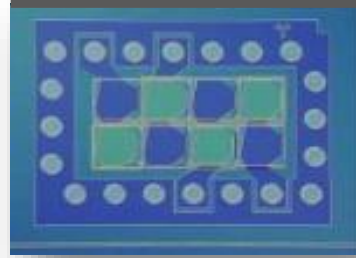
LCMA Lab.

Actuators Components



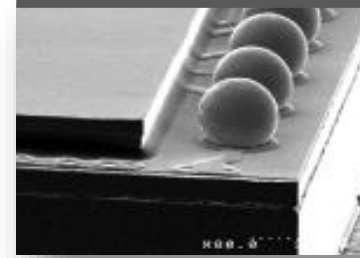
LCMC Lab.

Sensors Components



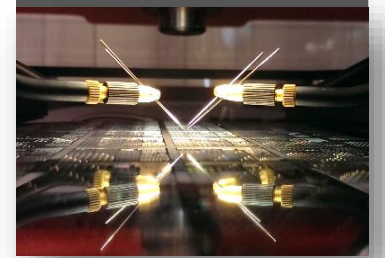
LCRF Lab.

RF Components



LP3D Lab.

Packaging & 3D



LCFC Lab.

Charact. & Reliability

Special MEMS Characterization tools



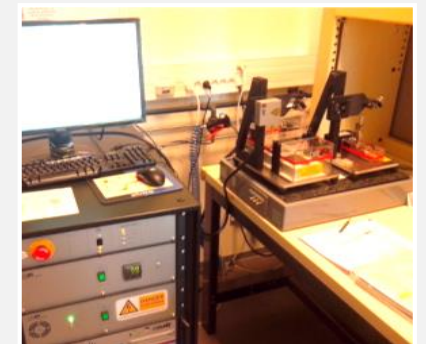
Residual Gas Analyzer



Laser vibrometer



200 mm semi-automated vacuum probe system

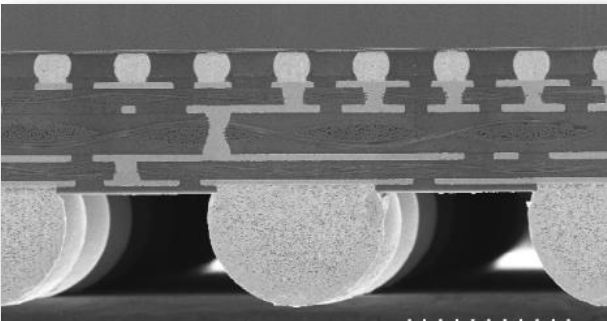
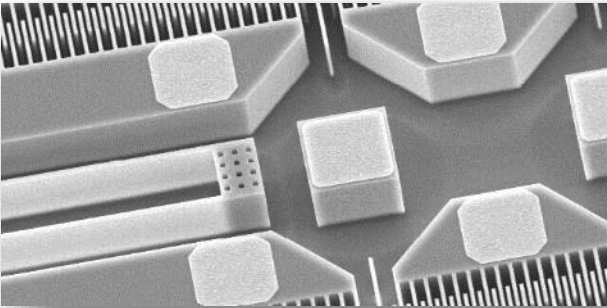


4-Point Bending system

WORLDWIDE INDUSTRIAL MICROSYSTEMS PARTNERSHIPS

ST Soitec Primo1D CERN aPSI elichens
SAFRAN APIX ANALYTICS cea dam mir sense hap2U





- 30+ years experience on MEMS
- 200+ people: **World's Largest MEMS R&D Institute**
- All 8" and 12" MEMS technologies in-house

- 330 patents portfolio in the MEMS field
- 30 new patents and 65 publications/year

- 25 ongoing industrial collaborations
- 20+ industrial transfers
- 7 startups creation



M&NEMS Multi-sensors Platform



MAIN MARKET TRENDS FOR MEMS SENSORS

Smart automobile



Mobile



Industry 4.0



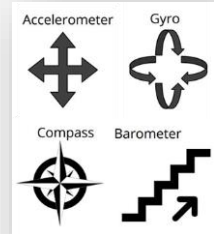
KEY MARKET DRIVERS

Cost

| Performances

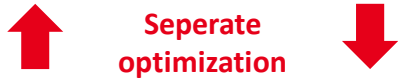
| Miniaturization

| Combo-sensor

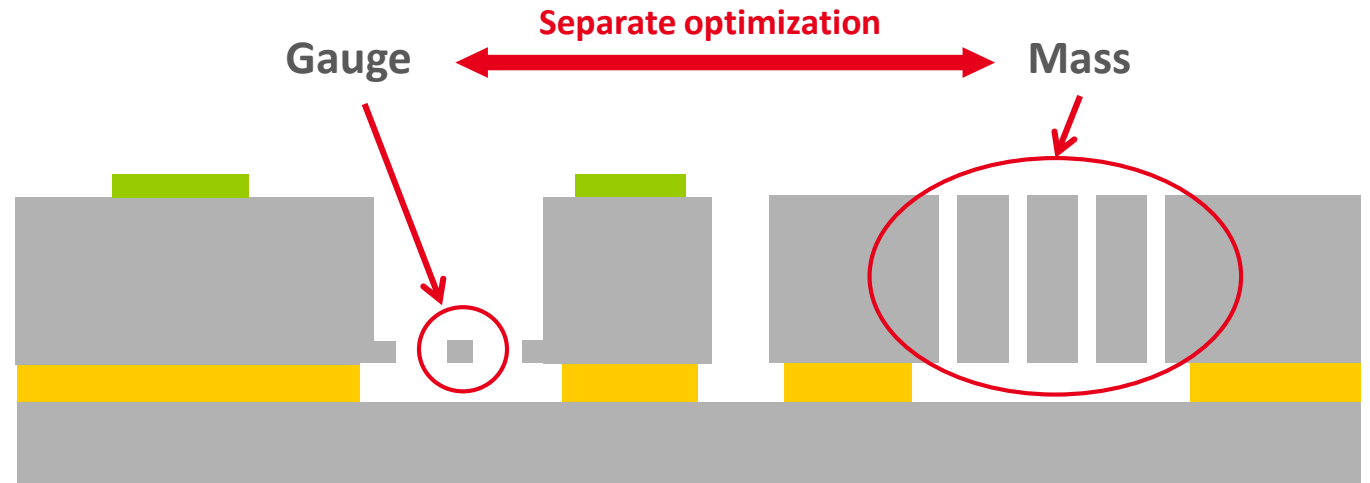
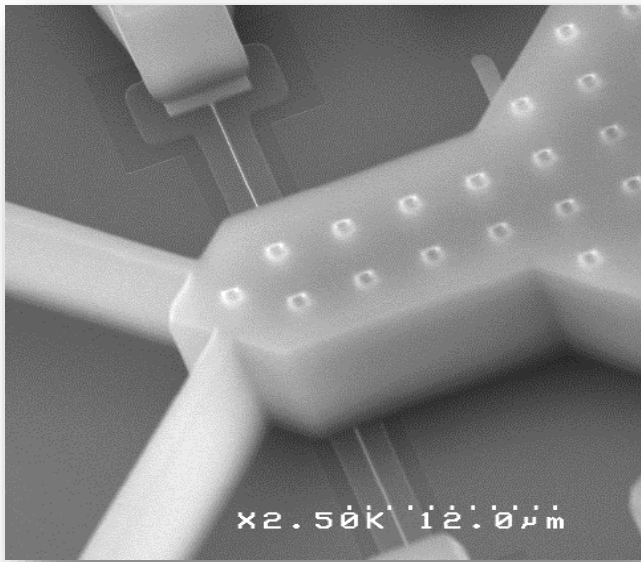


M&NEMS: WORLD-FIRST MULTI-SENSORS PLATFORM

MEMS size mechanical part



Nano-size piezoresistive gauge



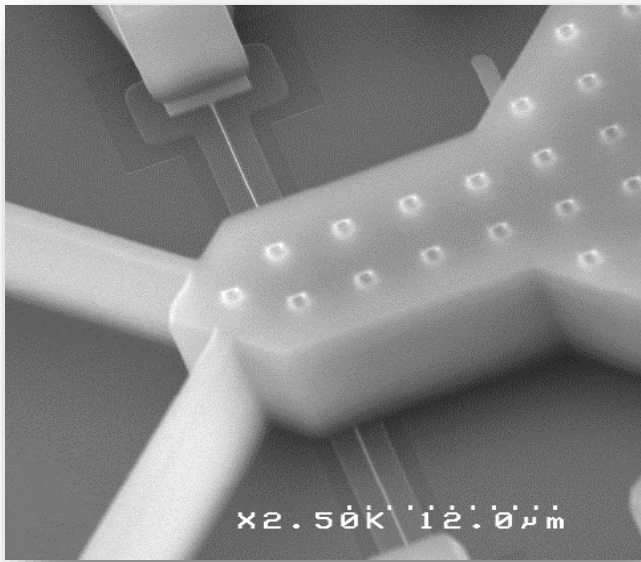
- Ultra-Miniaturized
- High performance
- Combo sensors
- Low power

M&NEMS: WORLD-FIRST MULTI-SENSORS PLATFORM

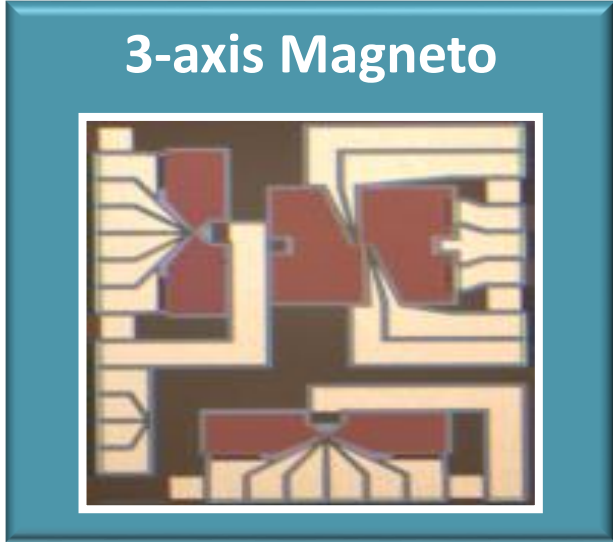
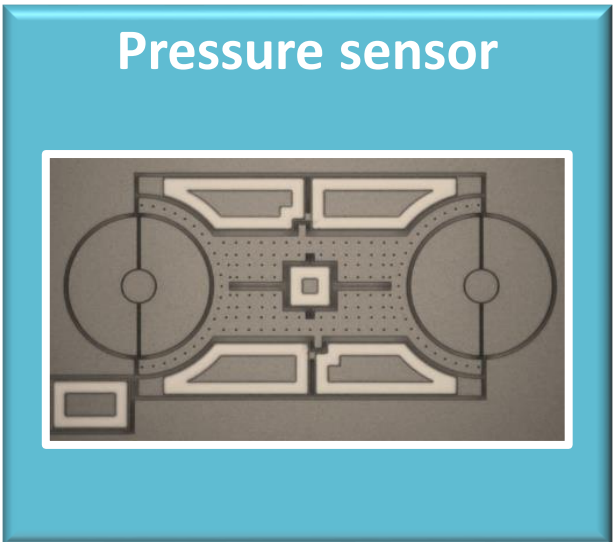
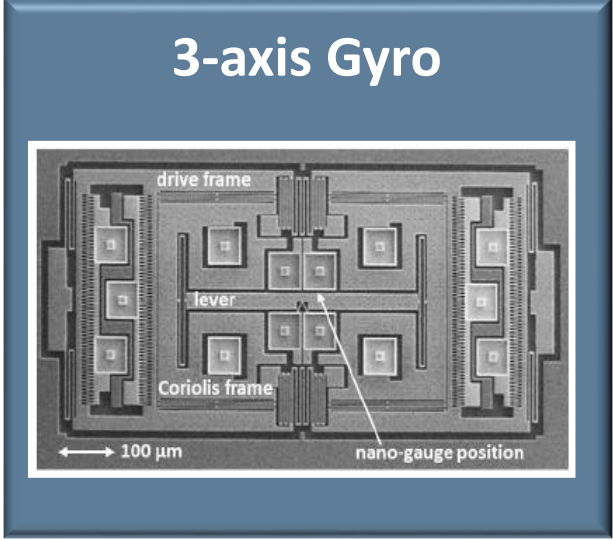
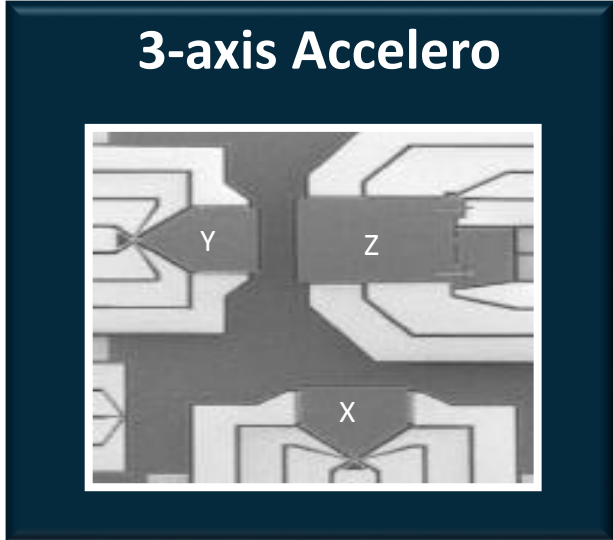
MEMS size mechanical part



Nano-size piezoresistive gauge



- Ultra-Miniaturized
- High performance
- Combo sensors
- Low power

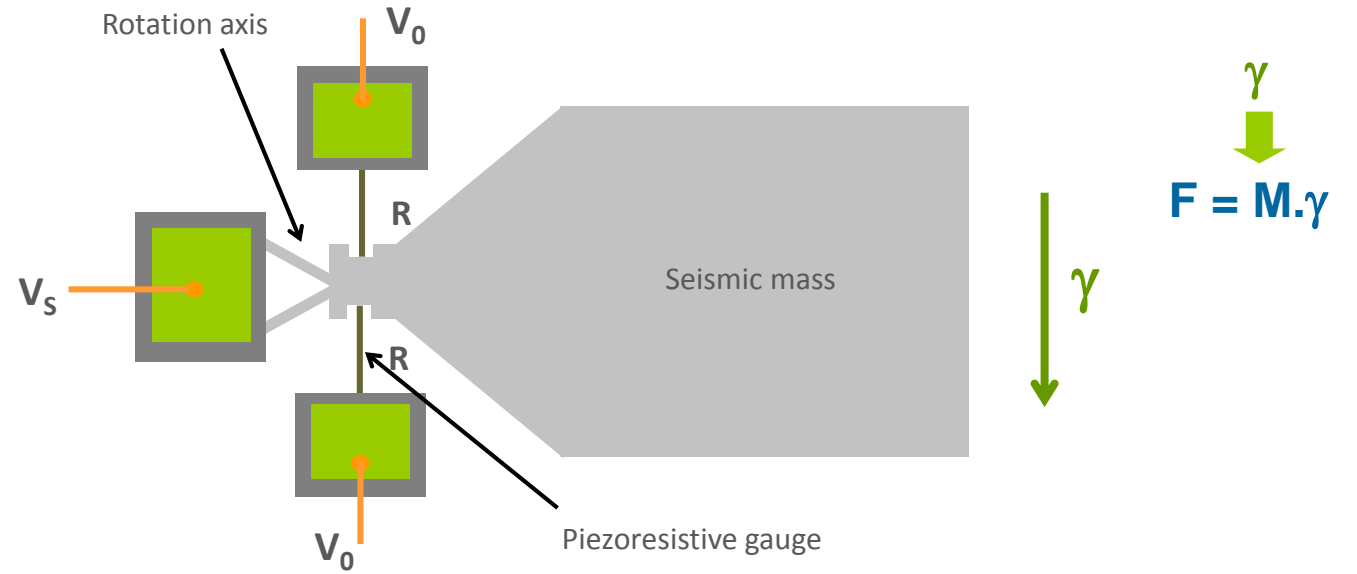
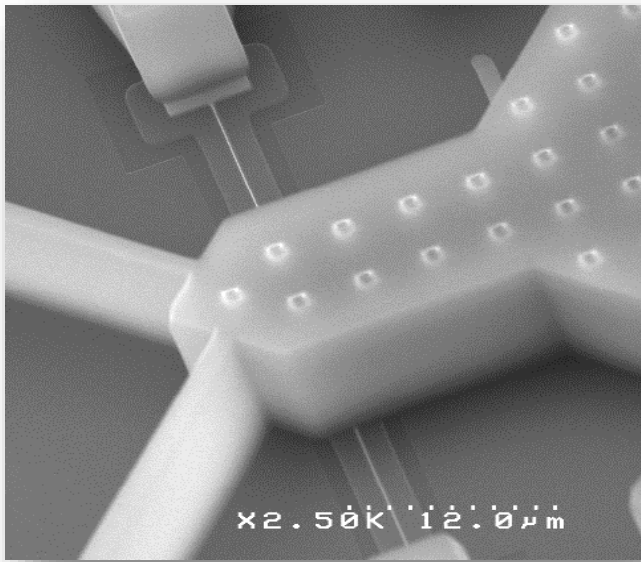


M&NEMS: WORKING PRINCIPLE

MEMS size mechanical part

↑ Separate optimization ↓

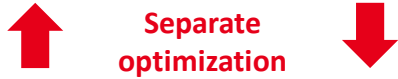
Nano-size piezoresistive gauge



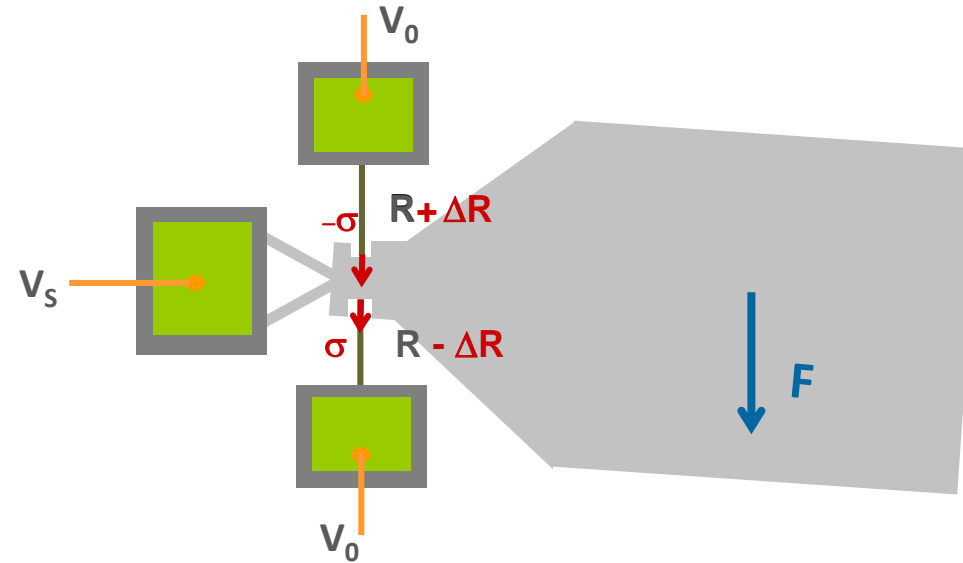
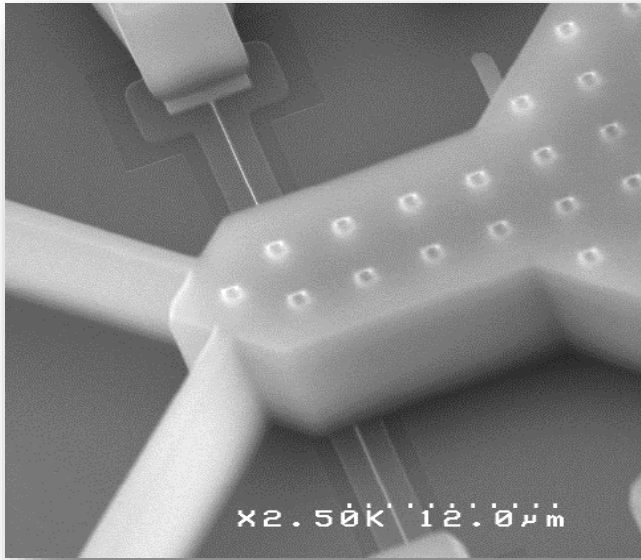
- Ultra-Miniaturized
- High performance
- Combo sensors
- Low power

M&NEMS: WORKING PRINCIPLE

MEMS size mechanical part



Nano-size piezoresistive gauge



$$F = M \cdot \gamma$$

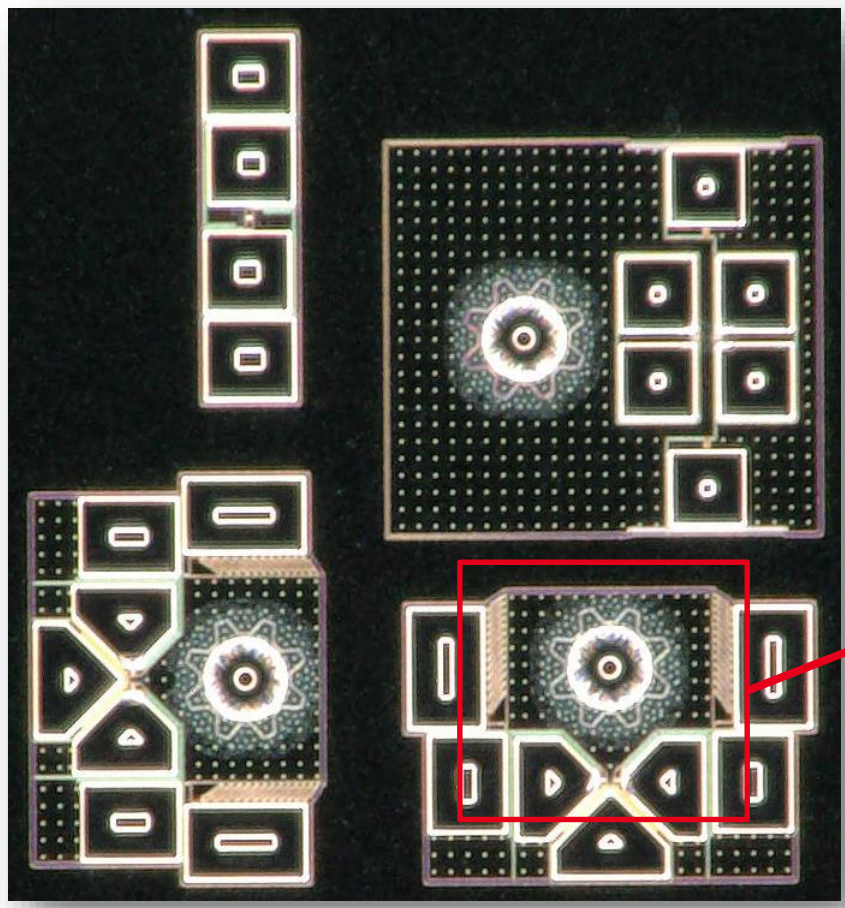
$$\frac{\Delta R}{R} = \pi \sigma$$

- Ultra-Miniaturized
- High performance
- Combo sensors
- Low power

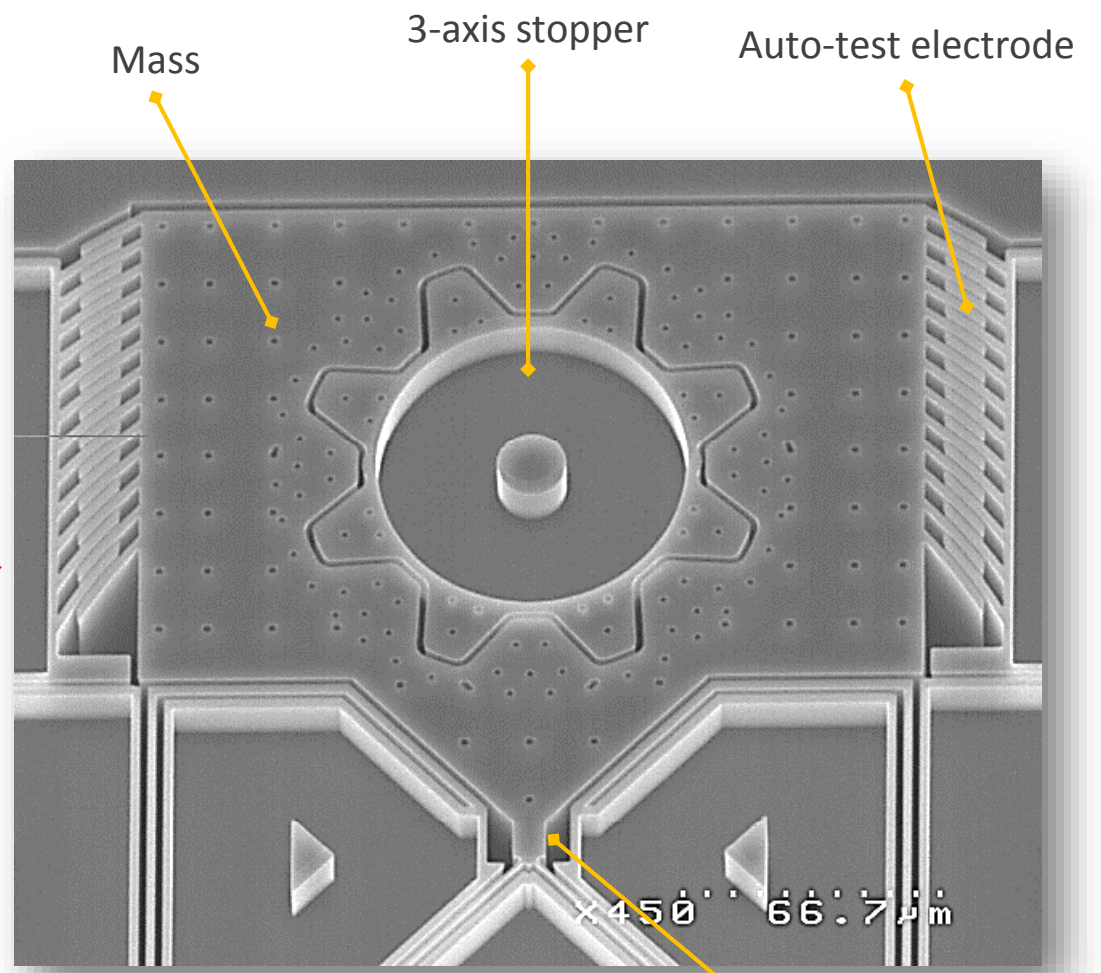
Stress magnification (sensitivity) induced by the use of nano-gauges

x100

M&NEMS 3-AXIS ACCELEROMETER

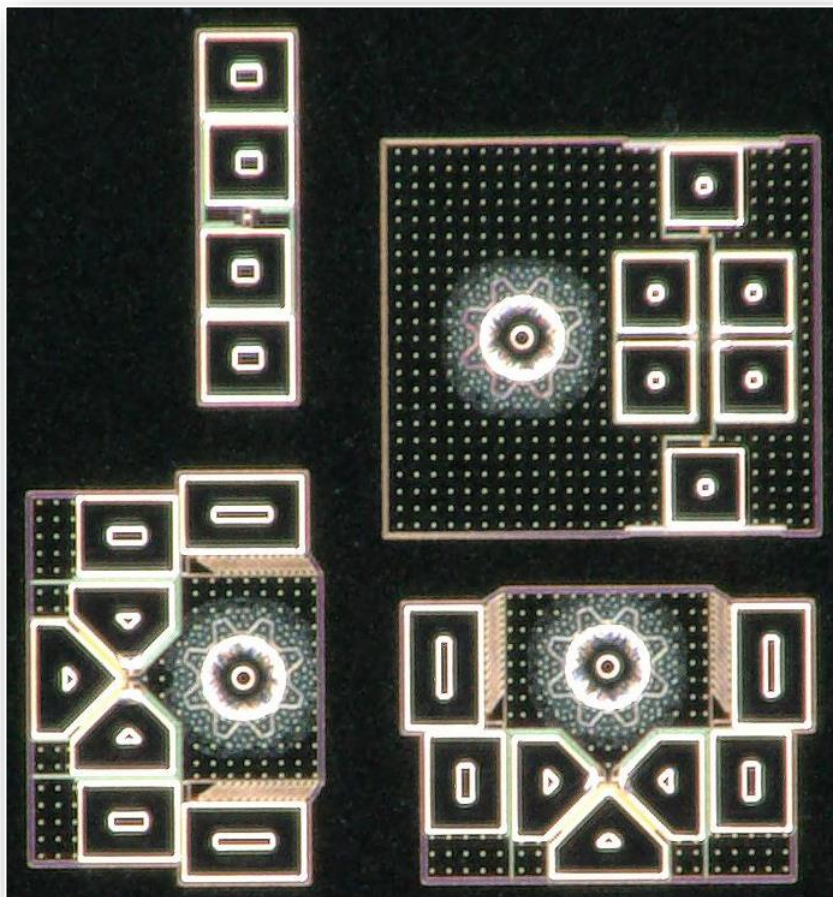


3-axis 20G Accelerometer
(optical microscope view)



(SEM view)

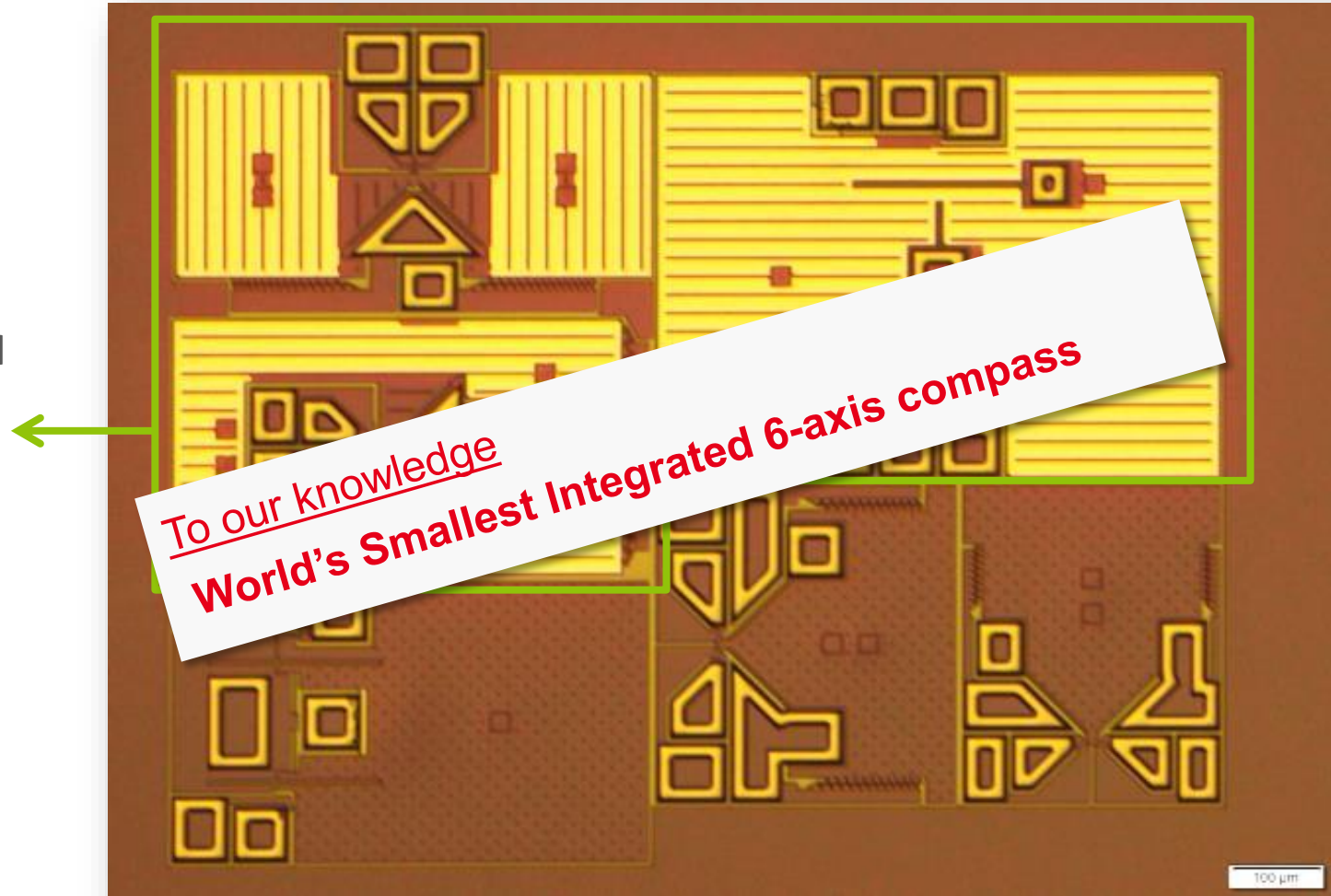
Nano-gauge



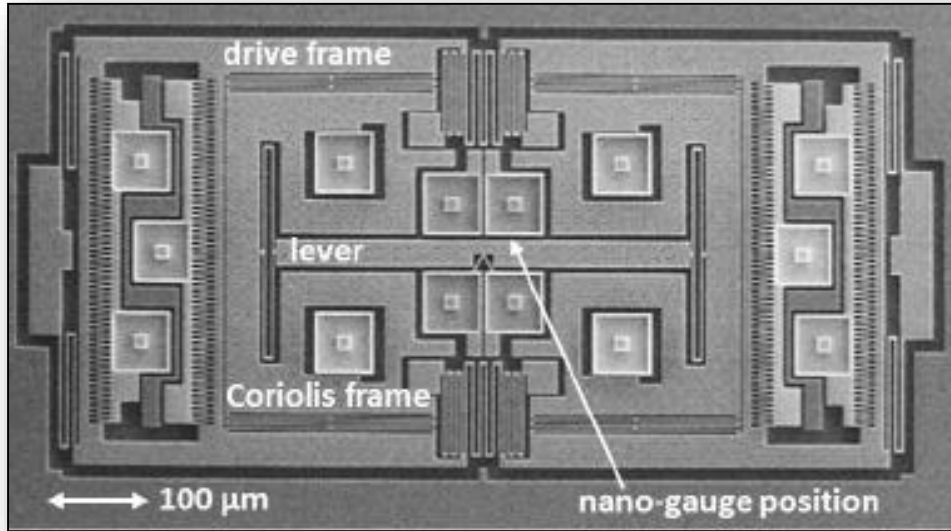
3-axis 20G Accelerometer
(optical microscope view)

- Sensitivity : **7 mV/mA/G**
- Offset variation before and after packaging **< 0.3% of the FS**

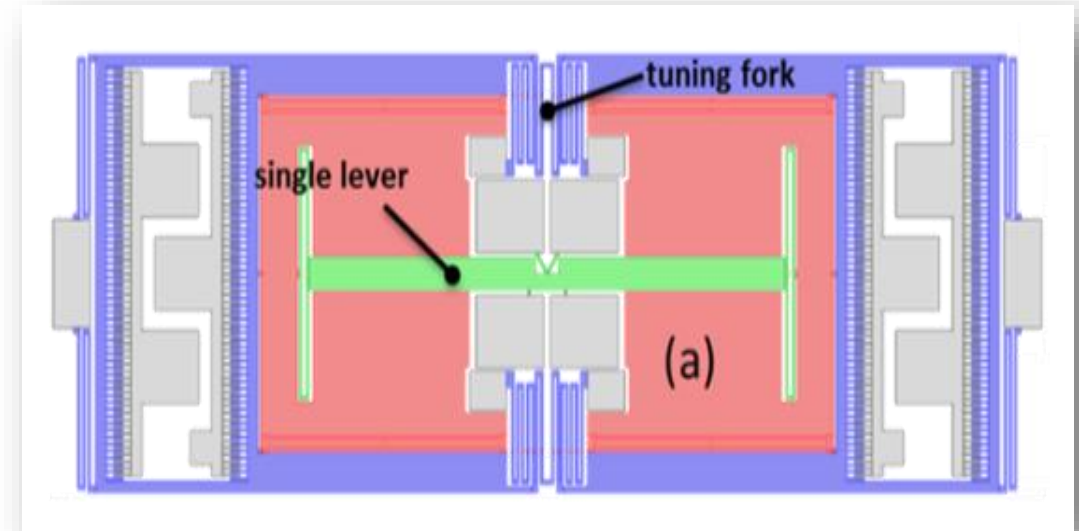
- **Robust to external field**
(x10 compare to Hall, GMR, TMR)
- **Low power**
- Low noise
- High range



6-axis M&NEMS compass
(mechanical footprint≈1.1mm²)



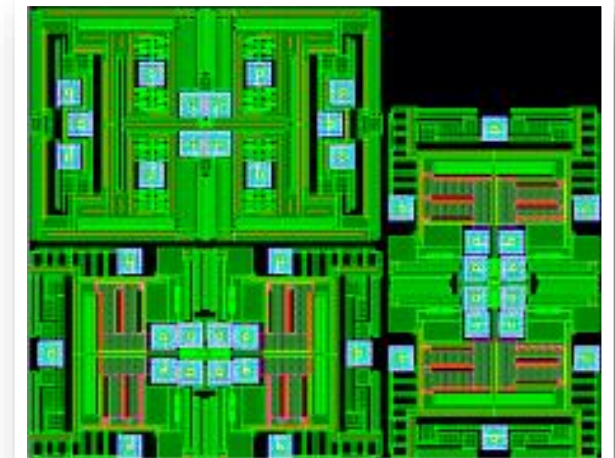
Device area: $800\mu\text{m} \times 450\mu\text{m}$ (0.36mm^2)

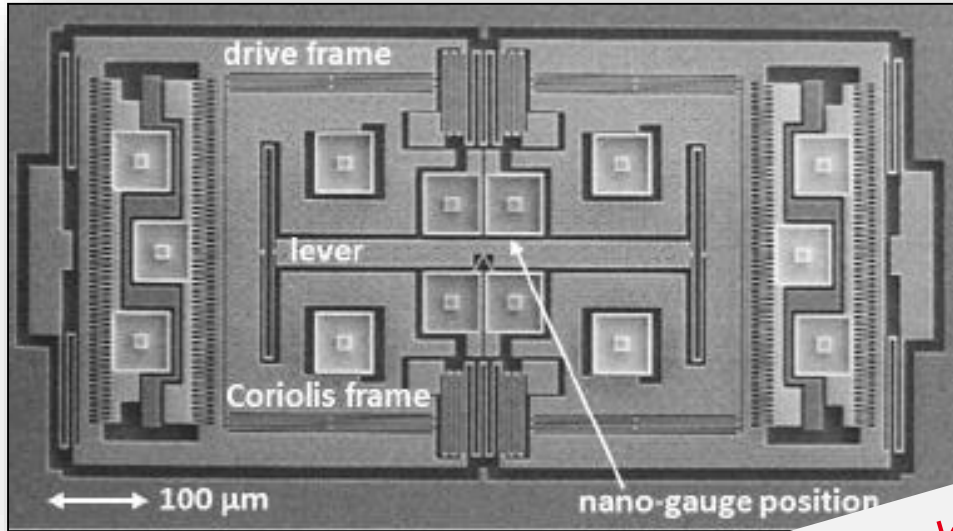


Nano-Gauge vs. Capacitive

- **Low impedance detection**
 - ⇒ No electrical coupling between drive and sense
 - ⇒ Not sensitive to parasitic capacitance
- **Force measurement vs. displacement**
 - ⇒ Well adapted for high frequency gyroscope
- **Linear detection**
 - ⇒ Less sensitive to vibration environment

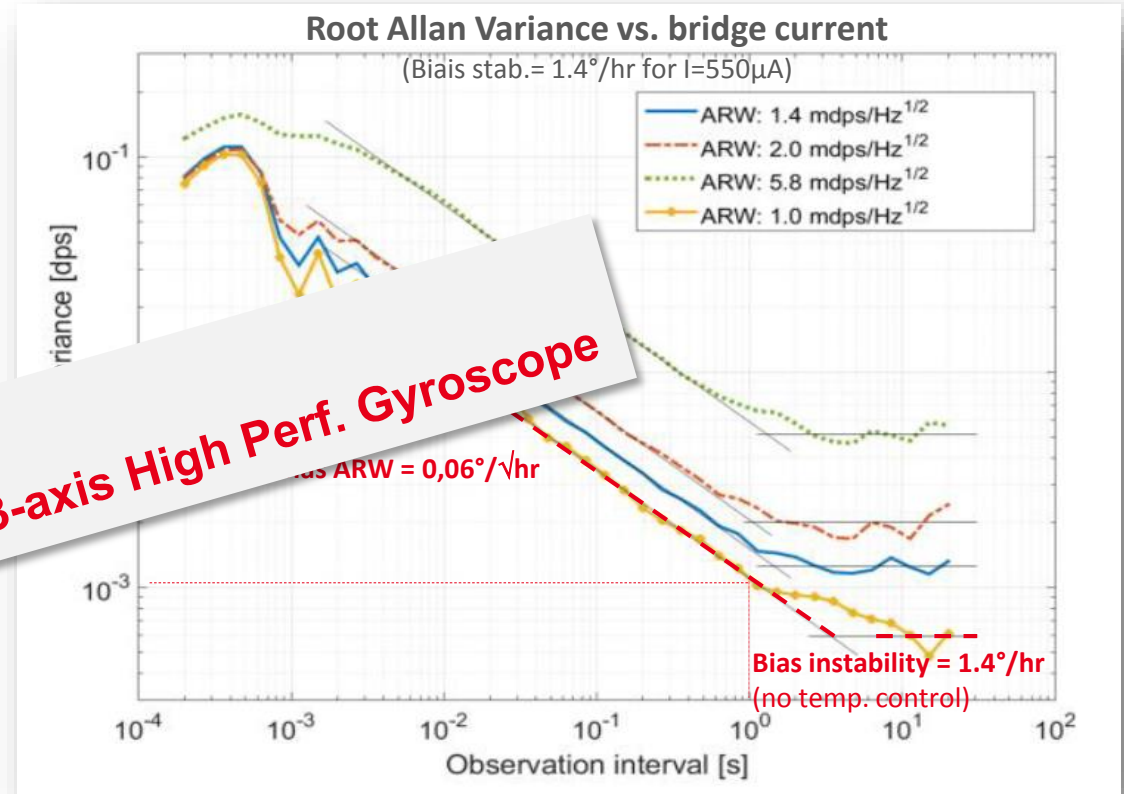
3-axis consumer gyro overall
area: **1.4 mm x 1.4 mm**





Device area: 800μm x 450μm (0.36mm²)

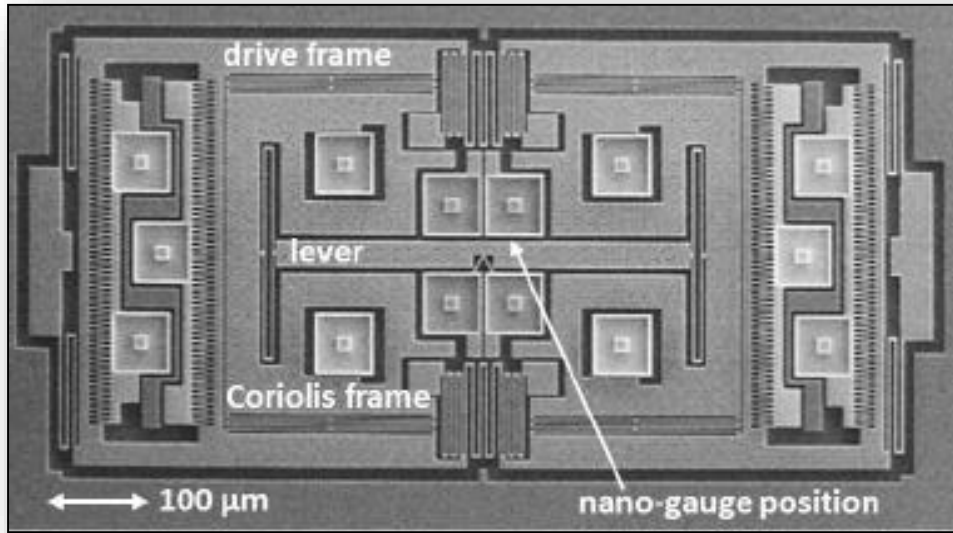
**To our knowledge
World's Smallest 3-axis High Perf. Gyroscope**



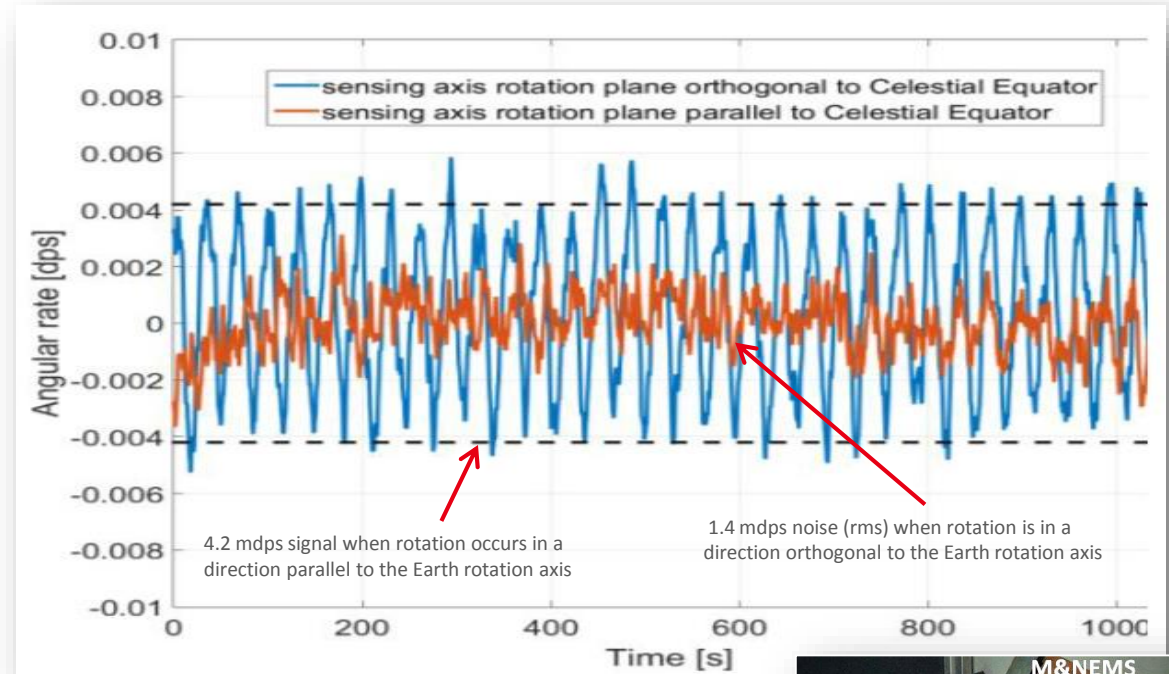
Nano-Gauge vs. Capacitive

- **Low impedance detection**
 - ⇒ No electrical coupling between drive and sense
 - ⇒ Not sensitive to parasitic capacitance
- **Force measurement vs. displacement**
 - ⇒ Well adapted for high frequency gyroscope
- **Linear detection**
 - ⇒ Less sensitive to vibration environment

- Bias Instability = **1.4°/hr**
- ARW = **0.06°/√hr**
- 3-Axis Gyro in **2mm²**



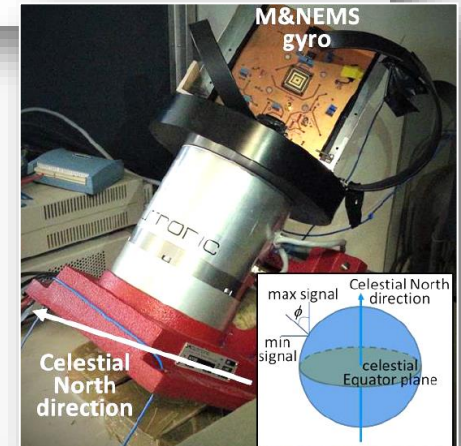
Device area: $800\mu\text{m} \times 450\mu\text{m}$ (0.36mm^2)

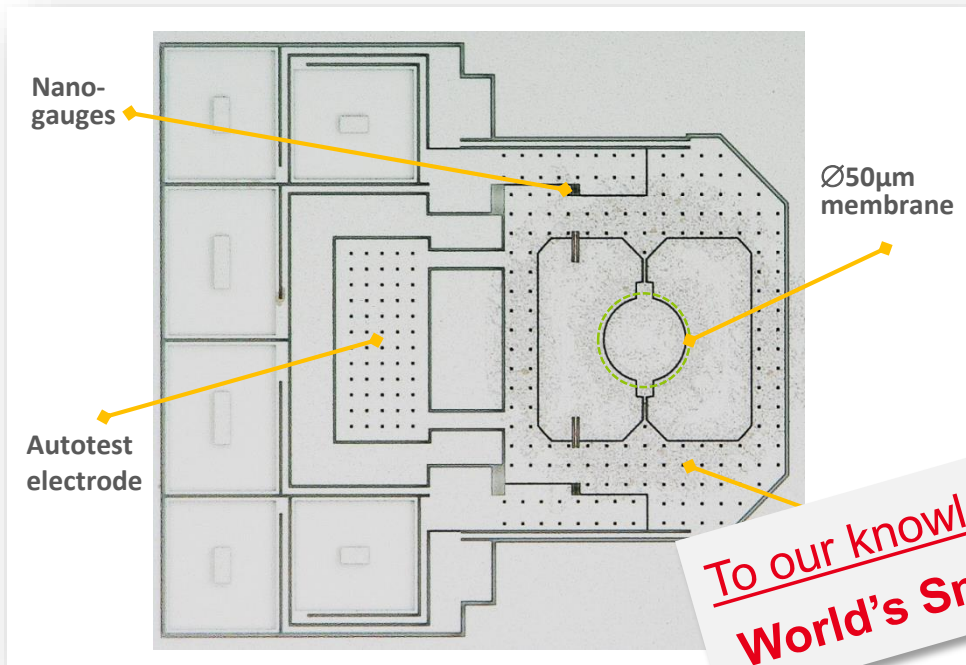


Nano-Gauge vs. Capacitive

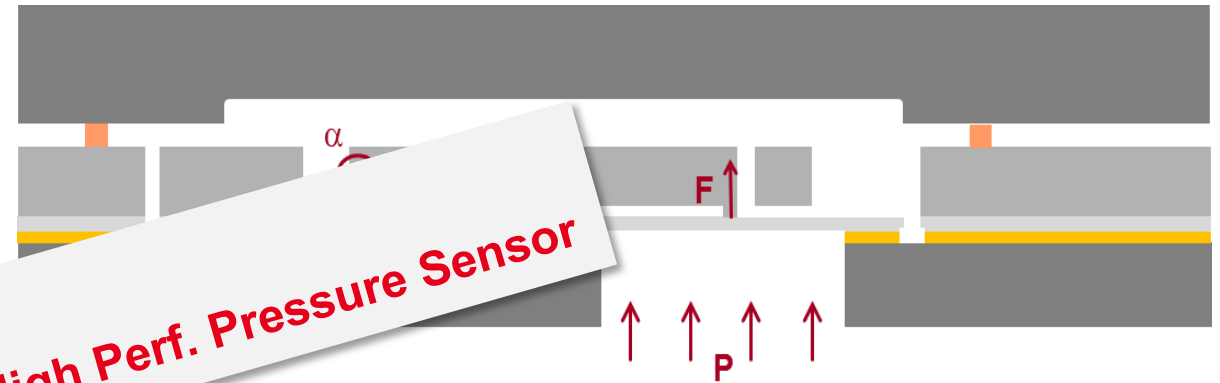
- **Low impedance detection**
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- **Linear detection**
 - ⇒ Less sensitive to vibration environment

Earth Rotation Measurement





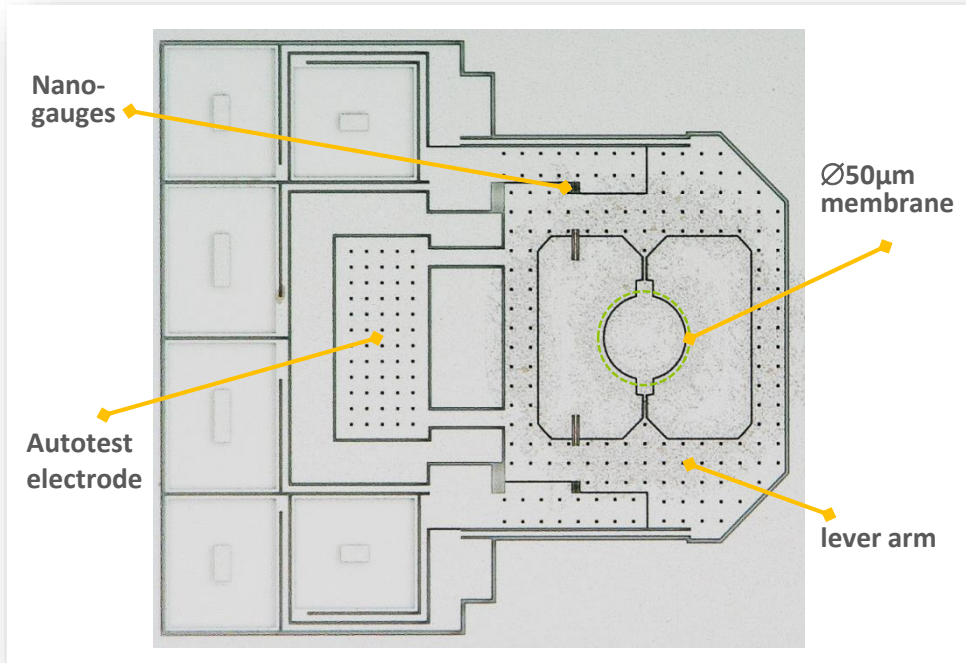
*To our knowledge
World's Smallest High Perf. Pressure Sensor*



- High linearity
- Gauge protected from external environment
- Over-pressure protection (stoppers)
- Vibration insensitive (balanced structure)
- Compatible with high temperature application

Barometric pressure sensor

- Range : **1.4 bar**
- Resolution : **1.2 Pa**
- Die size : **0.45 mm²** (Mechanical footprint : 0,12mm²)



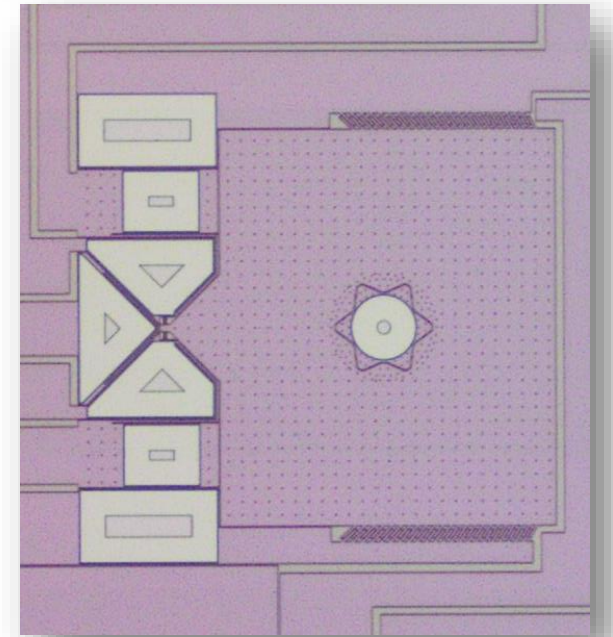
- High linearity
- Gauge protected from external environment
- Over-pressure protection (stoppers)
- Vibration insensitive (balanced structure)
- Compatible with high temperature application

Thermal Cycling [-20°C / +125°C]

- TCO < 1 Pa/°C
- Non-Linearity < 0.2% FS
- TCS < 10ppm/°C
- Accuracy < 100 Pa

Results are obtained after only 1 cycle

- **World-first high performances multi-sensors platform** demonstrated
- **Reliability for the automotive field** is addressed with very promising results (thermal behavior, shock, vibration...)
- **Further improvements are still to be explored** (design, technology, packaging...)
- **Under development :**
 - High-end gyroscope ($0.1^\circ/\text{h}$)
 - Resonant detection for high-end 3-axis accelerometer, magnetometer and pressure sensor



**Thank you for
your attention**



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